PATENT 1794-0141P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Yoshinobu AOYAGI et al. Conf.:

6758

Appl. No.:

09/941,612

Group:

1765

Filed:

August 30, 2001

Examiner: UNKNOWN

For:

IMPURITY DOPING METHOD FOR SEMICONDUCTOR

AS WELL AS SYSTEM THEREFOR AND SEMICONDUCTOR MATERIALS PREPARED THERESICEIVED

LETTER

TC 1700

Assistant Commissioner for Patents Washington, DC 20231

Sir:

Enclosed herewith is a Supplemental Declaration that should be made part of the record of the present application.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fee required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

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KM/glh 1794-0141P

Attachment

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